

## Supplementary Information

### Machine-Learning Prediction of Metal Sulfide Photocatalysts for Sacrificial Hydrogen Evolution under Visible Light Irradiation

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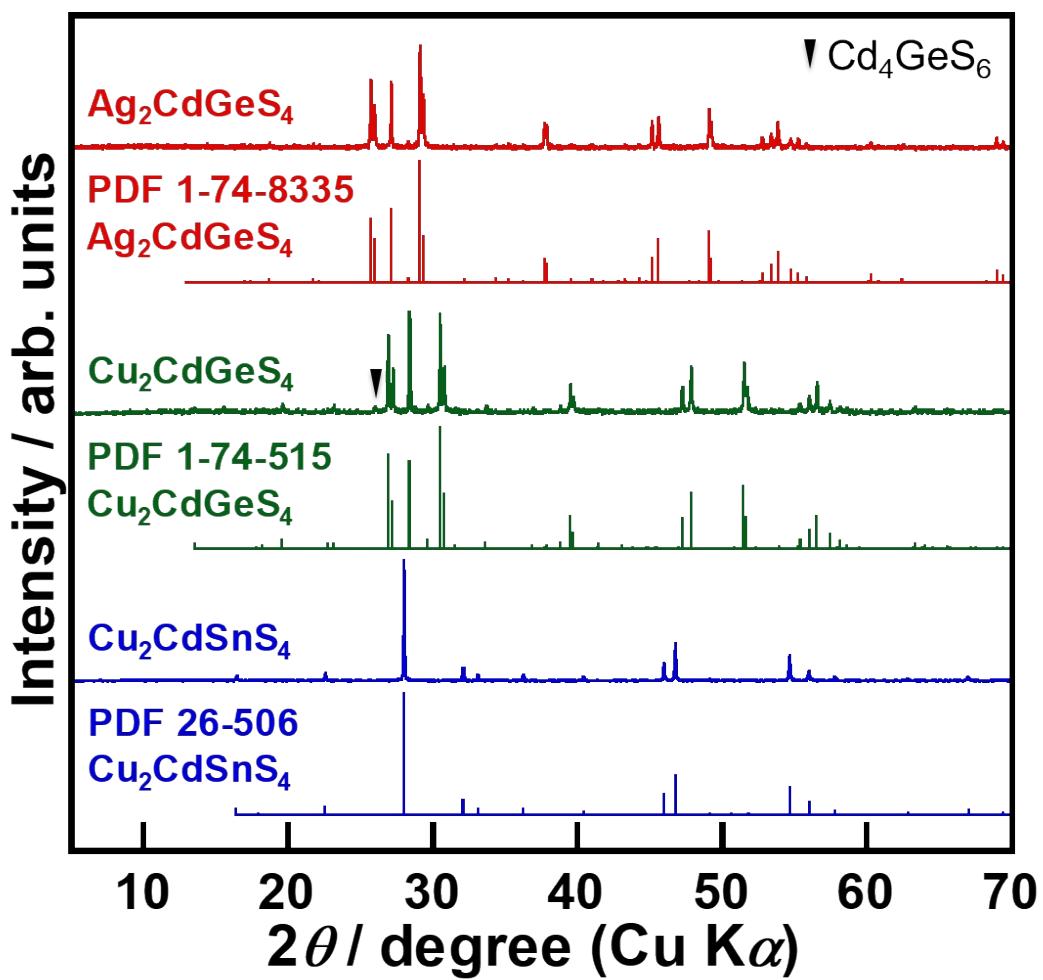
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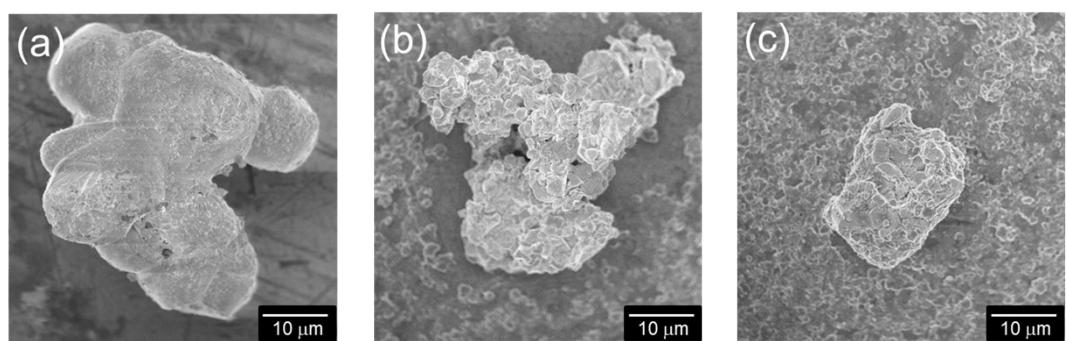
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**Table S1** Conditions of convergence criteria for geometric optimization

Self-consistent field tolerance / eV atom <sup>-1</sup> / eV atom <sup>-1</sup>	Energy tolerance	Maximum force tolerance / eV Å <sup>-1</sup>	Displacement tolerance / Å	Max stress / GPa
1.0×10 <sup>-6</sup>	1.0×10 <sup>-5</sup>	0.03	1×10 <sup>-3</sup>	0.1



**Figure S1** XRD patterns of  $\text{Ag}_2\text{CdGeS}_4$  and  $\text{Cu}_2\text{CdMS}_4$  ( $\text{M}=\text{Ge}$  and  $\text{Sn}$ ) prepared by a solid-state reaction. Patterns due to  $\text{K}\alpha_2$  were eliminated.



**Figure S2** SEM images of (a)  $\text{Ag}_2\text{CdGeS}_4$ , (b)  $\text{Cu}_2\text{CdGeS}_4$  and (c)  $\text{Cu}_2\text{CdSnS}_4$  prepared by a solid-state reaction.

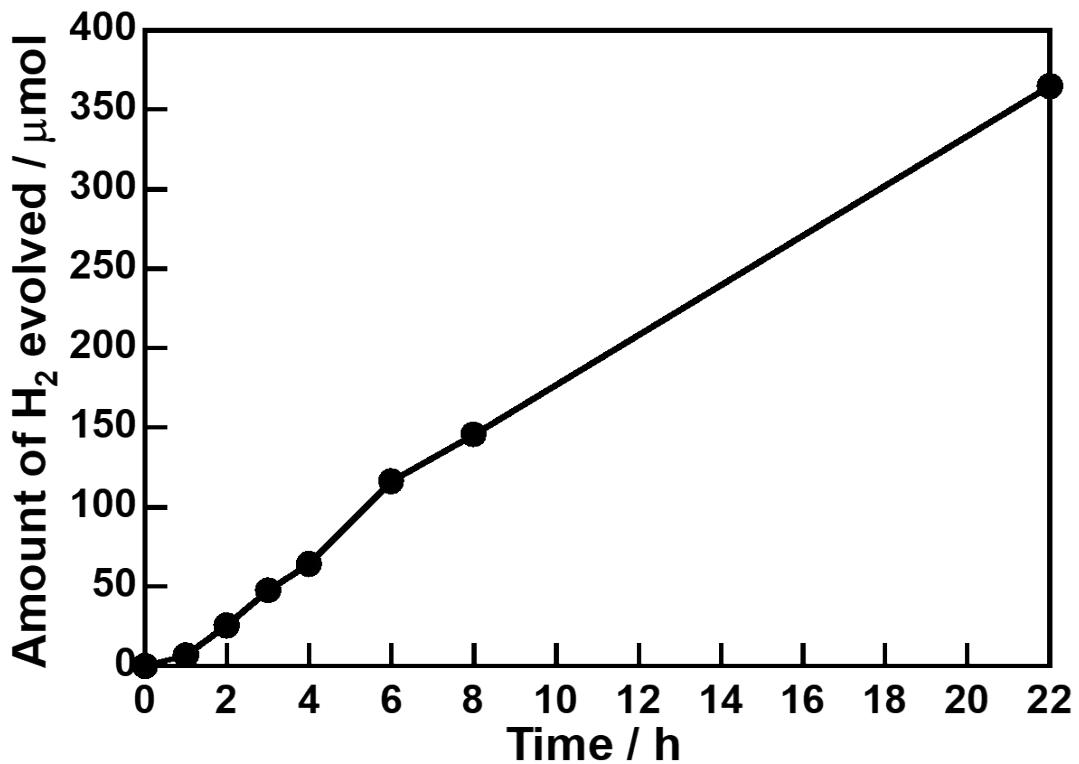


Figure S3  $\text{H}_2$  evolution over a Ru-loaded  $\text{Cu}_2\text{CdSnS}_4$  photocatalyst prepared by a solid-state reaction from an aqueous solution containing sacrificial reagents under visible light irradiation. Photocatalyst: 0.3 g, cocatalyst: photodeposition *in situ*, reactant solution: 0.5 mol  $\text{L}^{-1}$   $\text{K}_2\text{SO}_3$  and 0.1 mol  $\text{L}^{-1}$   $\text{Na}_2\text{S}$  aqueous solution (120 mL), cell: top-irradiation cell with a Pyrex window, light source: 300 W Xe lamp with a cut-off filter (HOYA: L42).